



AFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

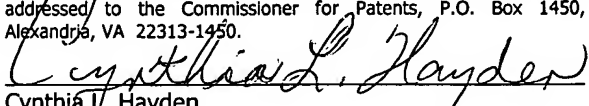
In re Applicant:	§	
Ilya Karpov et al.	§	Art Unit: 2814
	§	
Serial No.: 10/822,361	§	Examiner: Long Pham
	§	
Filed: April 12, 2004	§	Docket: ITL.0835D1US
	§	P14730D
For: Fabricating Deeper and Shallower	§	
Trenches in Semiconductor Structures	§	Assignee: Intel Corporation
	§	

Mail Stop **Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO PAPER NO. 03152005**

Sir:

In response to the office action mailed March 21, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: May 24, 2005  
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.  
  
Cynthia L. Hayden